

Introduction to the Special Issue on Silicon Photonics

THE GUEST editors of the IEEE JOURNAL OF SELECTED TOPICS IN QUANTUM ELECTRONICS (JSTQE) are pleased to introduce this issue on Silicon Photonics. The 41 papers in this issue describe some of the most exciting work in the field and are a testament to the creativity and vitality of the area of Si photonics and to the researchers, who are carrying out the experiments and theory. There are 16 invited papers written by leading researchers that comprehensively treat topics ranging from devices to circuits and systems on a silicon chip. The remaining 25 contributed papers are no less important in their discussion of important results in topics such as silicon modulators, silicon light sources, and nonlinear processes in silicon.

This special issue would not have been possible without the professionalism, dedication, and expertise of all the members of our publication team. In particular, the guest editors would like to express thanks to the authors, both invited and contributed, for submitting comprehensive and thought-provoking papers. A special thanks goes to the international peer reviewers who donated their time and skill to maintain the technical quality of this special edition while also staying within tight deadlines. The coordination of this issue was handled with skill and grace by C. Tan-Yan, and the production tasks were resourcefully managed by the IEEE staff. We are sincerely grateful to these individuals for their assistance and support. Finally, the editors

would like to thank Dr. F. Bartoli for inviting us to serve the semiconductor integrated photonics community and for helping us complete this complex, but always rewarding task.

MICHAL LIPSON, *Primary Guest Editor*
Electrical and Computer Engineering
Cornell University, Ithaca, NY 14853 USA
ml292@cornell.edu

RICHARD M. OSGOOD, JR., *Guest Editor*
Electrical Engineering and Applied Physics
Columbia University, NY 10027 USA
osgood@columbia.edu.

JUNG H. SHIN, *Guest Editor*
Department of Materials Science and Engineering
KAIST, Daejeon 305-701, Korea
jhs@kaist.ac.kr

KAZUMI WADA, *Guest Editor*
Department of Materials Engineering
The University of Tokyo, Tokyo, Japan
kwada@material.t.u-tokyo.ac.jp



Michal Lipson (SM'07) received the B.S., M.S., and Ph.D. degrees in physics in the Technion—Israel Institute of Technology, Haifa, Israel, in 1998.

In December 1998, she joined the Department of Material Science and Engineering, Massachusetts Institute of Technology (MIT) as a Postdoctoral Associate. In 2001, she joined the School of Electrical and Computer Engineering, Cornell University, where she is currently an Associate Professor. Her research at Cornell involves novel on-chip nanophotonic devices. She is the inventor of 12 patents regarding novel micron-size photonic structures for light manipulation. She is the author or coauthor of more than 100 papers in the major research journals in physics and optics.

Dr. Lipson is a Fellow of the Optical Society of America. She was the recipient of the National Science Foundation (NSF) CAREER Award in 2004.



Richard M. Osgood, Jr. (SM'82–F'87) received the B.S. degree in engineering from the U.S. Military Academy, New York, NY, the M.S. degree in physics from Ohio State University, Columbus, and the Ph.D. degree in physics from the Massachusetts Institute of Technology (MIT), Cambridge.

He is a Higgins Professor of electrical engineering and applied physics with Columbia University, New York. Prior to this appointment, he was a member of the Scientific Staff of MIT, Lincoln Laboratory (Solid State Physics Division), the U.S.A.F. Avionics Laboratory, and the U.S.A.F. Materials Laboratory. He was engaged in research in many areas of electrical engineering, physical chemistry, condensed matter physics, and optical physics. His most extensive research has been in the development of new infrared and ultraviolet lasers, the application of laser-induced chemistry to materials preparation, and optical surface physics and chemistry. From 2000, 2002, he was an Associate Director of Brookhaven National Laboratory in charge of all Basic Energy Sciences programs and the acting Director of its Nanocenter, the Center for Functional Nanomaterials.

He has authored or coauthored more than 400 journal publications.

Dr. Osgood is a Fellow of the APS and the Optical Society of America (OSA), and a member of the AVS, MRS, and ACS. In 1991, he received the R. W. Wood Prize from the OSA.



Jung H. Shin received the B.A. degree in physics from Harvard University, Cambridge, MA, in 1989 and the Ph.D. degree in applied physics from the California Institute of Technology (Caltech), Pasadena, in 1994.

He was a Postdoctoral Fellow with FOM-AMOLF, Amsterdam, the Netherlands. In 1996, he joined the Department of Physics, KAIST, where he is currently a Professor of physics, and the Head of the Graduate School of Nanoscience and Technology (WCU). His research interests include silicon-based materials in general, and their application for photonic, electronic, biofunctional devices and their integration.



Kazumi Wada received the Ph.D. degree in instrumentation engineering from Keio University, Yokohama, Japan.

He is currently a Professor of microphotronics, materials engineering with the University of Tokyo, Tokyo, Japan. In 1975, he joined the Research Laboratories, Nippon Telephone and Telegraph (NTT), Tokyo, where he was engaged in research on defects in Si and III–V materials and devices. During 1998, he was with the Microphotronics Center, Materials Science and Engineering, Massachusetts Institute of Technology (MIT), where he was engaged in conducting research on Si photonics. He focused on Ge photodetector and modulator on Si CMOS platform. During 2004, he joined the University of Tokyo, as a Professor, where he is involved in managing Microphotronics Laboratory for Si CMOS photonics research. Since 2008, he has been the coordinator of the Japan Society for the Promotion of Science (JSPS) program on Si Photonics Research Centers in the US, EU, and Japan. He has authored or coauthored more than 150 refereed journal papers and has edited 13 books. He was an Associate Editor of the *Japanese Journal of Applied*

Physics and the *Journal of Electronic Materials*.

He was the Chair of Si Photonics of Institute of Electrical, Information, and Communication Engineers (IEICE) in Japan, was a member of the Board of Directors of MRS, a Chair, and an International Advisory Committee Member of the international conference on Group IV Photonics (IEEE), and a Program Committee Member of SiGe Symposium at Electrochemical Society (ECS), the Program Committee Chair of the International Conference on Solid State Devices and Materials sponsored by the Japanese Society of Applied Physics (JSAP). He was an Associate Editor of the IEEE/TMS. He is a Fellow of JSAP and to serve the Director of JSAP 2010.